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**UNITED STATES PATENT APPLICATION**

of

**ROGER W. PHILLIPS**

RICHARD L. BONKOWSKI

PATRICK K. HIGGINS ·

and

**CHARLES T. MARKANTES**

for

# OPTICALLY VARIABLE SECURITY DEVICES

WORKMAN, NYDEGGER &amp; SEELEY

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ATTORNEYS AT LAW  
1000 EAGLE GATE TOWER  
60 EAST SOUTH TEMPLE  
SALT LAKE CITY, UTAH 84111

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1           Diffraction grating technology has been employed in the formation of two-  
2 dimensional holographic patterns which create the illusion of a three-dimensional image to  
3 an observer. Three-dimensional holograms have also been developed based on differences  
4 in refractive indices in a polymer using crossed laser beams, including one reference beam  
5 and one object beam. Such holograms are called volume holograms or 3D holograms.  
6 Furthermore, the use of holographic images on various objects to discourage counterfeiting  
7 has found widespread application.

8           There currently exist several applications for surfaces embossed with holographic  
9 patterns which range from decorative packaging such as gift wrap, to security documents  
10 such as bank notes and credit cards. Two-dimensional holograms typically utilize diffraction  
11 patterns which have been formed on a plastic surface. In some cases, a holographic image  
12 which has been embossed on such a surface can be visible without further processing;  
13 however, it is generally necessary, in order to achieve maximum optical effects, to place a  
14 reflective layer, typically a thin metal layer such as aluminum, onto the embossed surface.  
15 The reflective layer substantially increases the visibility of the diffraction pattern  
16 embossment.

17           Every type of first order diffraction structure, including conventional holograms and  
18 grating images, has a major shortcoming even if encapsulated in a rigid plastic. When  
19 diffuse light sources, such as ordinary room lights or an overcast sky, are used to illuminate  
20 the holographic image, all diffraction orders expand and overlap so that the diffraction colors  
21 are lost and not much of the visual information contained in the hologram is revealed. What  
22 is typically seen is only a silver colored reflection from the embossed surface and all such  
23 devices look silvery or pastel, at best, under such viewing conditions. Thus, holographic  
24 images generally require direct specular illumination in order to be visualized. This means  
25 that for best viewing results, the illuminating light must be incident at the same angle as the  
26 viewing angle.

1 Since the use of security holograms has found widespread application, there exists  
2 a substantial incentive for counterfeiters to reproduce holograms which are frequently used  
3 in credit cards, banknotes, and the like. Thus, a hurdle that security holograms must  
4 overcome to be truly secure, is the ease at which such holograms can be counterfeited. One  
5 step and two step optical copying, direct mechanical copying and even re-origination have  
6 been extensively discussed over the Internet. Various ways to counteract these methods have  
7 been explored but none of the countermeasures, taken alone, has been found to be an  
8 effective deterrent.

9 One of the methods used to reproduce holograms is to scan a laser beam across the  
10 embossed surface and optically record the reflected beam on a layer of a material such as a  
11 photopolymerizable polymer. The original pattern can subsequently be reproduced as a  
12 counterfeit. Another method is to remove the protective covering material from the  
13 embossed metal surface by ion etching, and then when the embossed metal surface is  
14 exposed, a layer of metal such as silver (or any other easily releasable layer) can be  
15 deposited. This is followed by deposition of a layer of nickel, which is subsequently released  
16 to form a counterfeiting embossing shim.

17 Due to the level of sophistication of counterfeiting methods, it has become necessary  
18 to develop more advanced security measures. One approach, disclosed in U.S. Patent Nos.  
19 5,624,076 and 5,672,410 to Miekka et al., embossed metal particles or optical stack flakes  
20 are used to produce a holographic image pattern.

21 A further problem with security holograms is that it is difficult for most people to  
22 identify and recollect the respective images produced by such holograms for verification  
23 purposes. The ability of the average person to authenticate a security hologram conclusively  
24 is compromised by the complexity of its features and by confusion with decorative diffractive  
25 packaging. Thus, most people tend to confirm the presence of such a security device rather  
26

1 than verifying the actual image. This provides the opportunity for the use of poor  
2 counterfeits or the substitution of commercial holograms for the genuine security hologram.

3 In other efforts to thwart counterfeiters, the hologram industry has resorted to more  
4 complex images such as producing multiple images as the security device is rotated. These  
5 enhanced images provide the observer with a high level of "flash" or aesthetic appeal.  
6 Unfortunately, this added complexity does not confer added security because this complex  
7 imagery is hard to communicate and recollection of such imagery is difficult, if not  
8 impossible, to remember.

9 It would therefore be of substantial advantage to develop improved security products  
10 which provide enhanced viewing qualities in various lighting conditions, especially in diffuse  
11 lighting, and which are usable in various security applications to make counterfeiting more  
12 difficult.

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These and other aspects and features of the present invention will become more fully apparent from the following description and appended claims, or may be learned by the practice of the invention as set forth hereinafter.

**BRIEF DESCRIPTION OF THE DRAWINGS**

In order to more fully understand the manner in which the above-recited and other advantages and objects of the invention are obtained, a more particular description of the invention will be rendered by reference to specific embodiments thereof which are illustrated in the appended drawings. Understanding that these drawings depict only typical embodiments of the invention and are not therefore to be considered as limiting of its scope, the invention will be described and explained with additional specificity and detail through the use of accompanying drawings in which:

Figure 1 is a schematic depiction of a security article according to one embodiment of the present invention;

Figure 2 is a schematic depiction of a security article according to another embodiment of the present invention;

Figure 3 is a schematic depiction of a security article according to a further embodiment of the present invention;

Figure 4 is a schematic depiction of a security article according to another embodiment of the present invention;

Figure 5 is a schematic depiction of a security article according to yet another embodiment of the present invention;

Figure 6 is a schematic depiction of a security article according to a further embodiment of the present invention;

Figure 7 is a schematic depiction of a security article according to another embodiment of the present invention;

Figure 8A is a schematic depiction of a security article according to a further embodiment of the present invention;

Figure 8B is an enlarged sectional view of the security article of Figure 8A;



1 Figure 9 is a schematic depiction of a security article according to another  
2 embodiment of the present invention;

3 Figure 10A is a schematic depiction of a prelamine structure used to form a security  
4 article according to an additional embodiment of the present invention;

5 Figure 10B is a schematic depiction of a security article formed from the prelamine  
6 structure of Figure 10A;

7 Figure 11 is a schematic depiction of a security article according to another  
8 embodiment of the present invention;

9 Figure 12 is a schematic depiction of a security article according to an alternative  
10 embodiment of the present invention;

11 Figure 13 is a schematic depiction of a security article according to an additional  
12 embodiment of the present invention;

13 Figure 14 is a schematic depiction of a security article according to another  
14 embodiment of the present invention;

15 Figure 15 is a schematic depiction of a hot stamping process used to form one  
16 embodiment of a security article according to the invention;

17 Figure 16 is a schematic depiction of a hot stamping process used to form another  
18 embodiment of a security article according to the invention;

19 Figures 17A and 17B are diagrams showing the geometries of various viewing  
20 conditions used in measuring the optical characteristics of a security article of the invention;

21 Figure 18 is a graph showing the spectral profiles for a security article of the  
22 invention;

23 Figure 19 is a graphical representation of the CIE Lab color space showing trajectory  
24 of color for a security article of the invention;

25 Figure 20 is a graph showing the off-gloss spectral profiles for a security article of  
26 the invention;

1 Figure 21 is a graph showing the on-gloss spectral profiles for a security article of the  
 2 invention;

3 Figure 22 is a graph showing the on-gloss spectral profiles for a security article of the  
 4 invention;

5 Figure 23 is a photomicrograph of a thin film optical stack used in a security article  
 6 of the invention; and

7 Figures 24A and 24B are photomicrographs showing holographic relief at the top of  
 8 a thin film optical stack used in a security article of the invention.

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ical interference pattern 14 formed on the outer surface 12 can take various conventional forms including diffraction patterns, refraction patterns, holographic patterns, conventional holographic images, corner cube reflector patterns, zero order diffraction patterns, moiré patterns, and patterns on microstructures having dimensions in the range of from about  $0.1\mu\text{m}$  to about  $1\mu\text{m}$ , and various combinations thereof, including images, or other like interference patterns.

The particular methods and structures that form optical interference pattern 14 are known by those skilled in the art. For example, embossing the light transmissive substrate to form an interference pattern such as a hologram thereon can be done by well known

1 The Kinegram® device is a two-dimensional, computer-generated image (available  
2 from OVD Kinegram Corp. of Switzerland) in which the individual picture elements are  
3 filled with light-diffracting microstructures. These microstructures are extremely fine surface  
4 modulations with typical dimensions of less than one micrometer.

5 Generally, moldable thermoformable materials are used to form light transmissive  
6 substrate 12 and include, for example, plastics such as polyethylene terephthalate (PET),  
7 especially PET type G, polycarbonate, acrylics such as polyacrylates including polymethyl  
8 methacrylate (PMMA), polyacrylonitrile, polyvinyl chloride, polystyrene, cellulose diacetate  
9 and cellulose triacetate, polypropylene, polydicyclopentadiene, mixtures or copolymers  
10 thereof, and the like. In one preferred embodiment, light transmissive substrate 12 is  
11 substantially composed of a transparent material such as polycarbonate. The substrate 12 is  
12 formed to have a suitable thickness of about 3µm to about 100µm, and preferably a thickness  
13 of about 12µm to about 25µm. In addition, substrate 12 can be made of one layer or multiple  
14 layers of substrate materials. Generally, substrate 12 should have a lower melting point or  
15 glass transition temperature than the optical coating, while being transparent.

16 In one method, substrate 12 can be produced from a thermoplastic film that has been  
17 embossed by heat softening the surface of the film and then passing the film through  
18 embossing rollers which impart the diffraction grating or holographic image onto the  
19 softened surface. In this way, sheets of effectively unlimited length can be formed with the  
20 diffraction grating or holographic image thereon. Alternatively, the diffractive surface can  
21 be made by passing a roll of plastic film coated with an ultraviolet (UV) curable polymer,  
22 such as PMMA, through a set of UV transparent rollers whereby the rollers set a diffractive  
23 surface into the UV curable polymer and the polymer is cured by a UV light that passes  
24 through the UV transparent rollers.

25 As shown in Figure 1, the color shifting optical coating 16 is a multilayer optical  
26 interference stack or foil that includes an absorber layer 18, a dielectric layer 20, and a

1 reflector layer 22. The absorber layer 18 can be deposited on light transmissive substrate 12  
2 by a conventional deposition process such as physical vapor deposition (PVD), sputtering,  
3 or the like. The absorber layer 18 is formed to have a suitable thickness of about 30-300 Å  
4 Angstroms (Å), and preferably a thickness of about 50-100 Å.

5 The absorber layer 18 can be composed of a semi-opaque material such as a grey  
6 metal, including metals such as chromium, nickel, titanium, vanadium, cobalt, and  
7 palladium, as well as other metals such as iron, tungsten, molybdenum, niobium, aluminum,  
8 and the like. Various combinations and alloys of the above metals may also be utilized, such  
9 as Inconel (Ni-Cr-Fe). Other absorber materials may also be employed in absorber layer 18  
10 including metal compounds such as metal sub-oxides, metal sulfides, metal nitrides, metal  
11 carbides, metal phosphides, metal selenides, metal silicides, and combinations thereof, as  
12 well as carbon, germanium, ferric oxide, metals mixed in a dielectric matrix, and the like.

13 The dielectric layer 20 can be formed on absorber layer 18 by a conventional  
14 deposition process such as PVD, chemical vapor deposition (CVD), plasma enhanced  
15 chemical vapor deposition (PECVD), reactive DC sputtering, RF sputtering, or the like. The  
16 dielectric layer 20 is formed to have an effective optical thickness for imparting color  
17 shifting properties to security article 10. The optical thickness is a well known optical  
18 parameter defined as the product  $\eta d$ , where  $\eta$  is the refractive index of the layer and  $d$  is the  
19 physical thickness of the layer. Typically, the optical thickness of a layer is expressed in  
20 terms of a quarter wave optical thickness (QWOT) that is equal to  $4\eta d/\lambda$ , where  $\lambda$  is the  
21 wavelength at which a QWOT condition occurs. The optical thickness of dielectric layer 20  
22 can range from about 2 QWOT at a design wavelength of about 400 nm to about 9 QWOT  
23 at a design wavelength of about 700 nm, and preferably 2-6 QWOT at 400-700 nm,  
24 depending upon the color shift desired. Suitable materials for dielectric layer 20 include  
25 those having a "high" index of refraction, defined herein as greater than about 1.65, as well  
26 as those have a "low" index of refraction, which is defined herein as about 1.65 or less.

1 Examples of suitable high refractive index materials for dielectric layer 20 include  
2 zinc sulfide (ZnS), zinc oxide (ZnO), zirconium oxide (ZrO<sub>2</sub>), titanium dioxide (TiO<sub>2</sub>),  
3 carbon (C), indium oxide (In<sub>2</sub>O<sub>3</sub>), indium-tin-oxide (ITO), tantalum pentoxide (Ta<sub>2</sub>O<sub>5</sub>), ceric  
4 oxide (CeO<sub>2</sub>), yttrium oxide (Y<sub>2</sub>O<sub>3</sub>), europium oxide (Eu<sub>2</sub>O<sub>3</sub>), iron oxides such as  
5 (II)diiron(III) oxide (Fe<sub>3</sub>O<sub>4</sub>) and ferric oxide (Fe<sub>2</sub>O<sub>3</sub>), hafnium nitride (HfN), hafnium carbide  
6 (HfC), hafnium oxide (HfO<sub>2</sub>), lanthanum oxide (La<sub>2</sub>O<sub>3</sub>), magnesium oxide (MgO),  
7 neodymium oxide (Nd<sub>2</sub>O<sub>3</sub>), praseodymium oxide (Pr<sub>6</sub>O<sub>11</sub>), samarium oxide (Sm<sub>2</sub>O<sub>3</sub>),  
8 antimony trioxide (Sb<sub>2</sub>O<sub>3</sub>), silicon carbide (SiC), silicon nitride (Si<sub>3</sub>N<sub>4</sub>), silicon monoxide  
9 (SiO), selenium trioxide (Se<sub>2</sub>O<sub>3</sub>), tin oxide (SnO<sub>2</sub>), tungsten trioxide (WO<sub>3</sub>), combinations  
10 thereof, and the like.

11 Suitable low refractive index materials for dielectric layer 20 include silicon dioxide  
12 (SiO<sub>2</sub>), aluminum oxide (Al<sub>2</sub>O<sub>3</sub>), metal fluorides such as magnesium fluoride (MgF<sub>2</sub>),  
13 aluminum fluoride (AlF<sub>3</sub>), cerium fluoride (CeF<sub>3</sub>), lanthanum fluoride (LaF<sub>3</sub>), sodium  
14 aluminum fluorides (*e.g.*, Na<sub>3</sub>AlF<sub>6</sub> or Na<sub>5</sub>Al<sub>3</sub>F<sub>14</sub>), neodymium fluoride (NdF<sub>3</sub>), samarium  
15 fluoride (SmF<sub>3</sub>), barium fluoride (BaF<sub>2</sub>), calcium fluoride (CaF<sub>2</sub>), lithium fluoride (LiF),  
16 combinations thereof, or any other low index material having an index of refraction of about  
17 1.65 or less. For example, organic monomers and polymers can be utilized as low index  
18 materials, including dienes or alkenes such as acrylates (*e.g.*, methacrylate), perfluoroalkenes,  
19 polytetrafluoroethylene (Teflon), fluorinated ethylene propylene (FEP), combinations  
20 thereof, and the like.

21 The-reflector layer 22 can be formed on dielectric layer 20 by a conventional  
22 deposition process such as PVD, sputtering, or the like. The reflector-layer 22 is formed to  
23 have a suitable thickness of about 300-1000 Å, and preferably a thickness of about 500-1000  
24 Å. The reflector layer 22 is preferably composed of an opaque, highly reflective metal such  
25 as aluminum, silver, copper, gold, platinum, niobium, tin, combinations and alloys thereof,  
26 and the like, depending on the color effects desired. It should be appreciated that semi-

1 opaque metals such as grey metals become opaque at approximately 350-400 Å. Thus,  
2 metals such as chromium, nickel, titanium, vanadium, cobalt, and palladium, or cobalt-nickel  
3 alloys, could also be used at an appropriate thickness for reflector layer 22.

4 In addition, reflector layer 22 can be composed of a magnetic material such as a  
5 cobalt-nickel alloy, or can be formed of a semitransparent material, to provide for machine  
6 readability for security verification. For example, machine readable information may be  
7 placed on a backing underlying the optical coating, such as personal identification numbers  
8 (PINS), account information, business identification of source, warranty information, or the  
9 like. In an alternative embodiment, reflector layer 22 can be segmented to allow for partial  
10 viewing of underlying information either visually or through the use of various optical,  
11 electronic, magnetic, or other detector devices. This allows for detection of information  
12 below optical coating 16, except in those locations where reflector segments are located,  
13 thereby enhancing the difficulty in producing counterfeits. Additionally, since the reflector  
14 layer is segmented in a controlled manner, the specific information prevented from being  
15 read is controlled, providing enhanced protection from forgery or alteration.

16 As shown in Figure 1, security article 10 can also optionally include an adhesive layer  
17 24 such as a pressure sensitive adhesive on reflector layer 22. The adhesive layer 24 allows  
18 security article 10 to be easily attached to a variety of objects such as credit cards, certificates  
19 of authenticity, bank cards, banknotes, visas, passports, driver licenses, immigration cards,  
20 and identification cards, as well as containers and other three-dimensional objects. The  
21 adhesive layer 24 can be composed of a variety of adhesive materials such as acrylic-based  
22 polymers, and polymers based on ethylene vinyl acetate, polyamides, urethane,  
23 polyisobutylene, polybutadiene, plasticized rubbers, combinations thereof, and the like.  
24 Alternatively, a hot stamping process, examples of which are discussed in further detail  
25 below, can be utilized to attach security article 10 to an object. By using an  
26 absorber/dielectric/reflector design for color shifting optical coating 16, such as shown in



1 Figure 1, high chroma variable color effects are achieved that are noticeable to the human  
2 eye. Thus, an object having security article 10 applied thereto will change color depending  
3 upon variations in the viewing angle or the angle of the object relative to the viewing eye,  
4 as well as variations in angles of incident light. As a result, the variation in colors with  
5 viewing angle increases the difficulty to forge or counterfeit security article 10. Furthermore,  
6 the thin film interference color shifting coating changes the diffractive colors, either  
7 suppressing, modifying or enhancing certain colors depending on the inherent color shifts  
8 of the diffractive and thin film structures. By way of example, the color-shifts that can be  
9 achieved utilizing color shifting optical coating 16 in accordance with the present invention  
10 include, but are not limited to, gold-to-green, green-to-magenta, blue-to-red, green-to-silver,  
11 magenta-to-silver, magenta-to-gold, etc.

12 The color shifting properties of optical coating 16 can be controlled through proper  
13 design of the layers thereof. Desired effects can be achieved through the variation of  
14 parameters such as thickness of the layers and the index of refraction of each layer. The  
15 changes in perceived color which occur for different viewing angles or angles of incident  
16 light are a result of a combination of selective absorption of the materials comprising the  
17 layers and wavelength dependent interference effects. The interference effects, which arise  
18 from the superposition of the light waves that have undergone multiple reflections and  
19 transmissions within the multilayered structure, are responsible for the shifts in perceived  
20 color with different angles.

21 Figure 2 depicts a security article 30 according to another embodiment of the present  
22 invention. The security article 30 includes elements similar to those discussed above with  
23 respect to security article 10, including a light transmissive substrate 12 formed with an  
24 optical interference pattern 14 on an outer first surface thereof, and a color shifting optical  
25 coating 16 formed on an opposing second surface of substrate 12. The optical coating 36 is  
26 a multilayer film that includes an absorber layer 18, a dielectric layer 20 thereon, and another

1 absorber layer 38, but does not include a reflector layer. This multilayer film configuration  
2 is disclosed in U.S. Patent No. 5,278,590 to Phillips et al., which is incorporated by  
3 reference herein. Such a film structure allows optical coating 36 to be transparent to light  
4 incident upon the surface thereof, thereby providing for visual verification or machine  
5 readability of information below optical coating 36 on a carrier substrate (not shown). An  
6 adhesive layer 24 such as a pressure sensitive adhesive can be optionally formed on absorber  
7 layer 38 if desired to allow attachment of security article 30 to an appropriate surface of an  
8 object.

9 Figure 3 depicts a security article 40 according to a further embodiment of the present  
10 invention. The security article 40 includes elements similar to those discussed above with  
11 respect to security article 10, including a light transmissive substrate 12 formed with an  
12 optical interference pattern 14 on an outer first surface thereof, and a color shifting optical  
13 coating 46 formed on an opposing second surface of substrate 12. The optical coating 46  
14 however, is a multilayer optical stack that includes all dielectric layers. Suitable optical  
15 stacks for optical coating 46 that include all dielectric layers are disclosed in U.S. Patent  
16 Nos. 5,135,812 and 5,084,351 to Phillips et al., the disclosures of which are incorporated  
17 herein by reference. Generally, optical coating 46 includes alternating layers of low and high  
18 index of refraction dielectric layers which can be composed of various materials such as  
19 those discussed above for dielectric layer 20. The all dielectric stack of optical coating 46  
20 enables security article 40 to be transparent to light incident upon the surface thereof. An  
21 adhesive layer 24 such as a pressure sensitive adhesive can be formed on optical coating 46  
22 if desired.

23 Figure 4 depicts a security article 50 according to a further embodiment of the present  
24 invention. The security article 50 includes elements similar to those discussed above with  
25 respect to security article 10, including a light transmissive substrate 12 formed with an  
26 optical interference pattern 14 on an outer first surface thereof, and a color shifting optical

1 coating 56 applied to an opposing second surface of substrate 12. The color shifting optical  
2 coating 56 is formed from a layer of color shifting ink or paint that includes a polymeric  
3 medium interspersed with a plurality of optical interference flakes having color shifting  
4 properties.

5 The color shifting flakes of optical coating 56 are formed from a multilayer thin film  
6 structure that includes the same basic layers as described above for the optical coating 16 of  
7 security article 10. These include an absorber layer, a dielectric layer, and optionally a  
8 reflector layer, all of which can be composed of the same materials discussed above in  
9 relation to the layers of optical coating 16. The flakes can be formed to have a symmetrical  
10 multilayer thin film structure, such as absorber/dielectric/reflector/dielectric/absorber, or  
11 absorber/dielectric/absorber. Alternatively, the flakes can have a nonsymmetrical structure,  
12 such as absorber/dielectric/reflector. The flakes are formed so that a dimension on any  
13 surface thereof ranges from about 2 to about 200 microns.

14 Typically, the multilayer thin film structure is formed on a flexible web material with  
15 a release layer thereon. The various layers are deposited on the web by methods well known  
16 in the art of forming thin coating structures, such as PVD, sputtering, or the like. The  
17 multilayer thin film structure is then removed from the web material as thin film color  
18 shifting flakes, which can be added to a polymeric medium such as various pigment vehicles  
19 for use as an ink or paint. In addition to the color shifting flakes, additives can be added to  
20 the inks or paints to obtain desired color shifting results. These additives include lamellar  
21 pigments such as aluminum flakes, graphite, mica flakes, and the like, as well as non-  
22 lamellar pigments such as aluminum powder, carbon black, and other colorants such as  
23 organic and inorganic pigments, and colored dyes.

24 Suitable embodiments of the flake structure are disclosed in a copending application  
25 Serial Number 09/198,733, filed on November 24, 1998, and entitled "Color Shifting Thin  
26 Film Pigments," which is incorporated herein by reference. Other suitable embodiments of



1 optical stack such as in optical coating 46 of security article 40. In addition, the optical  
2 coating of security article 60 can take the form of a color shifting ink or paint layer such as  
3 in optical coating 56 of security article 50.

4 Figure 6 depicts a security article 70 according to a further embodiment of the present  
5 invention. The security article 70 includes elements similar to those discussed above with  
6 respect to security article 60, including a light transmissive substrate 12 formed with an  
7 optical interference pattern 14 on an outer first surface thereof. A color shifting optical  
8 coating 76 is provided in the form of a foil that is laminated to a second opposing surface of  
9 substrate 12 by way of an adhesive layer 62. The optical coating 76 includes an absorber  
10 layer 18, a dielectric layer 20, and a reflector layer 22, which are formed on a carrier sheet  
11 64 prior to being laminated to substrate 12. The optical coating 76 further includes an  
12 essentially optically inactive interlayer 78 that is shear sensitive. The interlayer 78 is formed  
13 between dielectric layer 20 and reflector layer 22 by a conventional coating process and is  
14 composed of a very thin layer (*e.g.*, about 50-200 Å) of vapor deposited material such as  
15 polytetrafluoroethylene, fluorinated ethylene propylene (FEP), silicone, carbon, combinations  
16 thereof, or the like. The interlayer 78 makes it impossible to peel off security article 70 in  
17 an undamaged state once it has been applied to an object.

18 It should be understood that the shear interlayer as described for security article 70  
19 can be utilized if desired in the other above-described embodiments that utilize an optical  
20 coating comprising a multilayer foil. For example, Figure 7 depicts a security article 80  
21 that includes essentially the same elements as those discussed above with respect to security  
22 article 10, including a light transmissive substrate 12 having an optical interference pattern  
23 14, and a color shifting optical coating 86 having an absorber layer 18, a dielectric layer 20,  
24 and a reflector layer 22. The optical coating further includes an essentially optically inactive  
25 interlayer 88 that is formed between dielectric layer 20 and reflector layer 22. An adhesive  
26 layer 24 such as a pressure sensitive adhesive can optionally be formed on reflector layer 22,

1 or on an optional carrier sheet 64, such as a plastic sheet, to allow attachment of security  
2 article 80 to an appropriate surface of an object. In the latter case, the absorber layer would  
3 be adhesively bonded to light transmissive substrate 12 since carrier sheet 64 would carry the  
4 layers 18, 20, 88, and 22.

5 Figure 8A depicts a security article 90 according to another embodiment of the  
6 present invention in which the embossed surface of a substrate carries the optical coating.  
7 The security article 90 includes elements similar to those discussed above with respect to  
8 security article 10, including a light transmissive substrate 12 having an optical interference  
9 pattern 14 embossed on a surface thereof, and a color shifting optical coating 96 that is a  
10 multilayer film optical stack. The optical coating 96 is formed, however, on the same side  
11 as the interference pattern on substrate 12 by conventional vacuum deposition processes.  
12 The optical coating 96 includes an absorber layer 18, a dielectric layer 20 under absorber  
13 layer 18, and a reflector layer 22 under dielectric layer 20. Alternatively, the order of layer  
14 deposition can be reversed, *i.e.*, the absorber layer may be deposited first onto the optical  
15 interference pattern, followed by the dielectric layer, and finally the reflective layer. In this  
16 configuration, one can view the interference pattern such as a modified hologram by viewing  
17 the security article through light transmissive substrate 12.

18 Each of these layers of optical coating 96 formed on substrate 12 preferably conforms  
19 to the shape of the underlying interference pattern such as a holographic image, resulting in  
20 the holographic structure being present at the outer surface of optical coating 96. This is  
21 shown more clearly in the enlarged sectional view of security article 90 in Figure 8B. The  
22 vacuum processing utilized in forming optical coating 96 or other multilayer coating will  
23 maintain the holographic structure through the growing film so that the holographic image  
24 is retained at the outer surface of optical coating 96. This is preferably accomplished by a  
25 directed beam of vapor essentially normal to the coated surface. Such processing tends to  
26 replicate the initial structure throughout the optical stack to the outer surface.

1 An adhesive layer 24 such as a pressure sensitive adhesive can be optionally formed  
2 on a surface of substrate 12 opposite from optical coating 96 to allow attachment of security  
3 article 90 to an appropriate surface of an object.

4 It should be understood that in alternative embodiments of security article 90, optical  
5 coating 96 can take the form of a multilayer structure having absorber and dielectric layers  
6 with no reflector layer such as in optical coating 36 of security article 30, or can take the  
7 form of an all-dielectric optical stack such as in optical coating 46 of security article 40.

8 Figure 9 depicts a security article 100 according to another embodiment of the present  
9 invention which is formed from a master shim 102 used to replicate an interference structure  
10 such as a hologram in an optical stack. The master shim 102 is composed of a metallic  
11 material such as nickel, tin, chromium, or combinations thereof, and has a holographic or  
12 diffractive pattern 104 formed thereon. An optical coating 106 is formed on pattern 104 by  
13 conventional vacuum deposition processes such as physical vapor deposition. The optical  
14 coating 106 includes a release layer (not shown) directly deposited onto pattern 104, an  
15 absorber layer 18, a dielectric layer 20 on absorber layer 18, and a reflector layer 22 on  
16 dielectric layer 20. The release layer may be composed of a material such as gold, silicone,  
17 or a low surface energy material such as FEP. The dielectric layer is preferably a low index  
18 material such as  $MgF_2$  or  $SiO_2$  because of the stress benefits provided. Each of these layers  
19 of optical coating 106 is formed on master shim 102 so as to conform to the shape of the  
20 underlying holographic or diffractive pattern 104. A receiver sheet 108 such as a plastic  
21 sheet with an adhesive (not shown) is attached to reflector layer 22. The optical coating 106  
22 can then be stripped away from master shim 102 onto receiver sheet 108 for attachment onto  
23 an object, leaving the holographic or diffractive pattern replicated in optical coating 106.

24 In alternative embodiments of security article 100, optical coating 106 can take the  
25 form of a multilayer structure having absorber and dielectric layers with no reflector layer  
26

1 such as in optical coating 36 of security article 30, or can take the form of an all-dielectric  
2 optical stack such as in optical coating 46 of security article 40.

3 In the following embodiments, various security articles are formed by laminating  
4 laser imaged optical coating structures to embossed substrates. Lamination provides the  
5 advantage of being cost effective and secure since the two expensive security components  
6 (*i.e.*, the color shifting film and hologram) are kept separate until laminated together. The  
7 laminated articles can include either a color shifting foil or ink, which can be used as the  
8 background underneath a holographic image, with the holographic image capable of being  
9 seen only at selected angles. The hologram is thus seen superimposed on a color shifting  
10 background that also has an associated image.

11 In the embodiment illustrated in Figures 10A and 10B, a security article 110 is  
12 provided with laser ablated images formed in a color shifting optical coating 116. As shown  
13 in Figure 10A, optical coating 116 is formed on a carrier sheet 64 such as transparent PET  
14 by conventional coating processes to form a prelamine structure 117. The optical coating  
15 116 is formed by depositing a reflector layer 22 on carrier sheet 64, followed by deposition  
16 of a dielectric layer 20 and an absorber layer 18. A laser ablated image 118 is then formed  
17 in optical coating 116 on prelamine structure 117 by a conventional laser imaging system  
18 The laser ablated image 118 can take the form of digital images (*e.g.*, pictures of people,  
19 faces), bar codes, covert (*i.e.*, microscopic) data and information, or combinations thereof.  
20 The laser imaging can be accomplished by using a semiconductor diode laser system such  
21 as those available from Presstek, Inc. and disclosed in U.S. Patent Nos. 5,339,737 and  
22 Re. 35,512, the disclosures of which are incorporated by reference herein. Alternatively,  
23 reflective pattern etching, or chemical etching by photolithography can be utilized to form  
24 various images in the optical coating.

25 The prelamine structure 117 with laser ablated image 118 is then laminated to a  
26 a light transmissive substrate 12 having an optical interference pattern 14, such as a



It should be understood that prelamine structure 117 can be used as a final product if desired without subsequent lamination to an embossed substrate. In this case, prelamine structure 117 could be directly attached to an object by use of an adhesive or other attachment mechanism. The prelamine structure can also be prepared by directly laser ablating a suitable optically variable layer which has been directly deposited onto a holographic or diffractive substrate.

Figure 11 shows a security article 120 according to another embodiment of the invention which includes elements similar to those discussed above with respect to security article 110, including a light transmissive substrate 12 having an optical interference pattern 14 such as a holographic or diffractive pattern, and a color shifting optical coating 126 that is laminated to substrate 12 by an adhesive layer 62. The optical coating 126 includes an absorber layer 18, a dielectric layer 20, and a reflector layer 22. The optical coating 126 is deposited on a carrier sheet 64 to form a prelaminate structure prior to being laminated to substrate 12. The prelaminate structure is subjected to a laser imaging process such as described above for security article 110 in order to form a laser scribed number 122 such as a serial number for use in serialized labels.

Figure 12 depicts a security article 130 according to a further embodiment of the invention which includes elements similar to those discussed above with respect to security

1 articles 110 and 120, including a light transmissive substrate 12 formed with a holographic  
2 or diffractive pattern, and a color shifting optical coating 136 that is laminated to substrate  
3 12 by an adhesive layer 62. The optical coating 136 includes an absorber layer 18, a  
4 dielectric layer 20, and a reflector layer 22 as described above. The optical coating 136 is  
5 deposited on a carrier sheet 64 to form a prelamine structure prior to being laminated to  
6 substrate 12. The prelamine structure is subjected to a laser imaging process such as  
7 described above for security articles 110 and 120 in order to form both a laser ablated image  
8 118 as well as a laser scribed number 122, thereby combining the features of security articles  
9 110 and 120.

10 In an additional embodiment of the invention illustrated in Figure 13, a security  
11 article 140 includes elements similar to those discussed above with respect to security  
12 articles 130, including a light transmissive substrate 12 formed with an optical interference  
13 pattern 14, and a color shifting optical coating 146 that is laminated to a substrate 12 by way  
14 of an adhesive layer 62. The optical coating 146 includes an absorber layer 18, a dielectric  
15 layer 20, and a reflector layer 22 as described above, with optical coating 146 being  
16 deposited on a carrier sheet 64 to form a prelamine structure prior to being laminated to  
17 substrate 12. The prelamine structure is subjected to a laser imaging process such as  
18 described above for security article 130 in order to form both a laser ablated image 118 as  
19 well as a laser scribed number 122. In addition, a covert resistive layer 148 is formed on  
20 substrate 12 over interference pattern 14. The covert resistive layer 148 is composed of a  
21 transparent conductive material such as indium tin oxide (ITO), indium oxide, cadmium tin  
22 oxide, combinations thereof, and the like, and provides enhanced features to security article  
23 140 such as a defined electrical resistance. Such covert resistive layers are described in U.S.  
24 Patent Application Serial No. 09/094,005, filed June 9, 1998, the disclosure of which is  
25 incorporated herein by reference. The covert resistive layer can be applied to other  
26 embodiments of the invention if desired.

Sub  
A4

1 It should be understood that the above embodiments depicted in Figures 10-13 could  
2 alternatively be laminated obversely such that the embossed surface with a high index  
3 transparent dielectric layer is adjacent to the laminating adhesive and optical coating. For  
4 example, Figure 14 depicts a security article 150 which includes essentially the same  
5 elements security articles 130, including a light transmissive substrate 12 with an optical  
6 interference pattern 14, and a color shifting optical coating 156 that is laminated to substrate  
7 12 by way of an adhesive layer 62. The optical coating 156 includes an absorber layer 18,  
8 a dielectric layer 20, and a reflector layer 22. The optical coating 156 is deposited on a  
9 carrier sheet 64 to form a prelamine structure prior to being laminated to substrate 12. The  
10 prelamine structure is subjected to a laser imaging process to form both a laser ablated  
11 image 118 as well as a laser scribed number 122. As shown in Figure 14, the optical coating  
12 156 is laminated to substrate 12 so as to be adjacent to optical interference pattern 14 such  
13 as a holographic or diffractive pattern.

14 In various alternative embodiments of the security articles depicted in Figures 10-14,  
15 the optical coating can take the form of a multilayer structure having absorber and dielectric  
16 layers with no reflector layer such as in optical coating 36 of security article 30, or can take  
17 the form of an all-dielectric optical stack such as in optical coating 46 of security article 40.  
18 In addition, the optical coating of these security articles can take the form of a color shifting  
19 ink or paint layer such as in optical coating 56 of security article 50. Such alternative optical  
20 coatings would be formed directly on carrier sheet 64 prior to laser imaging and subsequent  
21 lamination.

22 It should be understood that the color shifting optical coatings deposited directly on  
23 embossed substrates, such as shown in the embodiments of Figures 1-4 and 7-9, can also be  
24 imaged if desired, such as by laser ablation as discussed above.

25 The security articles of the invention can be transferred and attached to various  
26 objects by a variety of attachment processes. One preferred process is hot stamping, which

1 is shown schematically in Figures 15 and 16. A hot stamp structure 160 according to one  
2 embodiment is illustrated in Figure 15 and includes a carrier sheet 162 having a thermal  
3 release layer 164 on one surface thereof. An embossed substrate 12 having an interference  
4 pattern 14 plus a high index transparent layer (not shown) on interference pattern 14 is  
5 attached to release layer 164 so that the release layer is on the side opposite of the  
6 embossing. A color shifting optical coating 166 which has been applied to substrate 12 as  
7 a solution coating of ink is interposed between substrate 12 and a thermally activated  
8 adhesive layer 168.

9 Generally, carrier sheet 162 can be composed of various materials such as plastics  
10 with various thicknesses which are known by those skilled in the art. For example, when  
11 carrier sheet 162 is formed of PET, the thickness preferably ranges from about 10  $\mu\text{m}$  to  
12 about 75 $\mu\text{m}$ . Other materials and thickness ranges are applicable in light of the teachings  
13 contained herein. Furthermore, carrier sheet 162 can be part of various manufacturing belts  
14 or other processing structures that assist in transferring the security article to a desired object.

15 The release layer 164 is composed of a suitable material to allow substrate 12 to be  
16 removed from carrier sheet 162 during the hot stamping process. The release layer 164 may  
17 be a polymeric material such as polyvinyl chloride, polystyrene, chlorinated rubber,  
18 acrylonitrile-butadiene-styrene (ABS) copolymer, nitrocellulose, methyl methacrylate, acrylic  
19 copolymers, fatty acids, waxes, gums, gels, mixtures thereof, and the like. The release layer  
20 164 can have a thickness of about 1  $\mu\text{m}$  to about 25  $\mu\text{m}$ .

21 The thermally activated adhesive layer 168 can be composed of various adhesive  
22 materials such as acrylic-based polymers, ethylene vinyl acetate, polyamides, combinations  
23 thereof, and the like. The adhesive layer 168 can have a thickness of about 2  $\mu\text{m}$  to about  
24 20  $\mu\text{m}$ .

25 During the hot stamping process, carrier sheet 162 is removed by way of release layer  
26 164 from substrate 12 after hot stamp structure 160 has been pressed onto a surface of an

1 object 169 to be hot stamped, with the security article composed of substrate 12 and optical  
2 coating 166 being bonded to object 169 by way of thermally activated adhesive layer 168.  
3 The object 169 may be composed of various materials such as plastics, polyester, leathers,  
4 metals, glass, wood, paper, cloth, and the like, *e.g.*, any material surface that requires a  
5 security device. The bonding of adhesive layer 168 against the surface of object 169 occurs  
6 as a heated metal stamp (not shown), having a distinct shape or image, comes into contact  
7 with object 169 which is heated to a temperature to provide a bond between object 169 and  
8 adhesive layer 168. The heated metal stamp simultaneously forces adhesive layer 168  
9 against object 169 while heating adhesive layer 168 to a suitable temperature for bonding to  
10 object 169. Furthermore, the heated metal stamp softens release layer 164, thereby aiding  
11 in the removal of carrier sheet 162 from substrate 12 in the areas of the stamp image to reveal  
12 the security article attached to object 169. Once the security article has been released from  
13 carrier sheet 162, the carrier sheet is discarded. When the security article has been attached  
14 to object 169, the image produced by the security article is viewed from substrate 12 toward  
15 optical coating 166.

16 A hot stamp structure 170 according to another embodiment is illustrated in Figure  
17 16 and includes essentially the same elements as hot stamp structure 160 discussed above.  
18 These include a carrier sheet 162 having a thermal release layer 164 on one surface thereof,  
19 and an embossed substrate 12 having an interference pattern 14, with substrate 12 attached  
20 to release layer 164. A color shifting multilayer optical coating 176 which has been applied  
21 to substrate 12 as a direct vacuum coating is interposed between substrate 12 and a thermally  
22 activated adhesive layer 168.

23 The hot stamping process for hot stamp structure 170 is the same as that described  
24 above for hot stamp structure 160. The carrier sheet 162 is removed by way of release layer  
25 164 from substrate 12 after hot stamp structure 170 has been pressed onto a surface of an  
26



1 the application document must depend on a limited array of security devices and a relatively  
2 non-skilled observer must be able to easily authenticate the devices. Credit cards, for  
3 example, usually depend on one major security device, and secondary devices such as  
4 printing techniques, for their authentication. The arsenal of tools available for banknote  
5 security (watermarks, intaglio, special paper, threads, etc.) cannot be applied to rigid opaque  
6 substrates. The security device of the invention, therefore, can be a very cost-effective  
7 "defensive shield" readily discerned by the public, and integrated into the overall style of the  
8 security document.

9 The security devices of the present invention also have the advantage of being suited  
10 to automated machine verification, while at the same time preserving an easily remembered  
11 feature, namely, a distinct color shift as the viewing angle is changed. Security can be  
12 further heightened by the incorporation of digital information that can be compared to the  
13 same image in photographic form. While the creative computer hacker might find ways to  
14 simulate a simple logo on a decorative holographic substrate, simulation of the color shifting  
15 background using an ink-jet printer is not possible and images cannot be created that appear  
16 only at certain viewing angles.

17 While conventional holograms provide an element of protection in document  
18 security, such holograms are difficult for the lay person to authenticate decisively since they  
19 exhibit eye-catching appeal, but do not naturally lead the observer into a correct  
20 determination. Building on the eye-catching appeal of holograms, the security articles of the  
21 invention add distinctive elements which are both easy to authenticate and difficult to  
22 replicate or simulate.

23 The following examples are given to illustrate the present invention, and are not  
24 intended to limit the scope of the invention.  
25  
26

Example 1

Optical coatings composed of color shifting flakes in a polymeric vehicle were formed by a drawdown process on light transmissive substrates composed of PET films containing a holographic image. The drawdown vehicle included two parts lacquer/catalyst and one part color shifting flakes. The color shifting flakes utilized had color shifting properties of green-to-magenta, blue-to-red, and magenta-to-gold.

Example 2

A color shifting optical coating having a three-layer design was formed on an embossed transparent film to produce a security article. The optical coating was formed on the flat surface of the transparent film on the side opposite from the embossed surface. The optical coating was formed by depositing an absorber layer composed of chromium on the flat surface of the transparent film, depositing a dielectric layer composed of magnesium fluoride on the absorber layer, and depositing a reflector layer of aluminum on the dielectric layer.

Alternatively, the aluminum layer can be deposited so that it is essentially transparent. This would allow printed information on an object to be read underneath the optical coating. Further, the reflector layer can alternatively be composed of a magnetic material. Such a magnetic feature in the color shifting component when added to the holographic component would give three independent security features to the security article.

The embossed film and optical coating forming the security article can be rigidly affixed to a carrier substrate, or can be attached to a release layer so that the security article can be hot stamped to a surface of an object. In addition, the hot stamped image of the color shifting thin film can be in the form of a pattern, as for example, dots, lines, logos, or other images. This pattern of optically variable effects will add an even greater degree of deterrence to counterfeiting.



Example 3

A security article was formed by laminating a laser imaged optical coating structure to an embossed substrate according to the present invention. The security article included four main parts: 1) A laser ablated image, 2) a laser ablated bar code or serial number, 3) a multilayer color shifting thin film, and 4) a holographic image.

The color shifting thin film was deposited in a vacuum roll coater onto a clear polyester (PET) substrate that was 1 mil thick. The thin film was formed by depositing a metal layer of aluminum on the substrate, followed by a dielectric layer composed of magnesium fluoride being deposited on the metal layer, and an absorber layer composed of chromium being deposited on the dielectric layer. Thereafter, the thin film was subjected to laser ablation using a laser diode imaging system based on the Heidelberg Quickmaster printing system to provide digital encoding. The imaging system used a high-resolution diode laser array with a spot size of approximately 30 microns. After the digital information had been encoded into the thin film, a plastic film embossed with a hologram was laminated to the thin film using a pressure sensitive adhesive to produce the completed security article. The hologram word "security" was placed upside down so as to place the embossed surface close to the thin film as well as to protect the image. The finished structure of the security article was similar to that shown for the embodiment of Figure 14 described above.

Upon visual inspection, the security article had three distinct images as it was rotated back and forth. At normal viewing, a profile of a woman's face created by laser ablation was seen in a magenta color, which at high angle shifted to a green color. This color shift was easy to see under various lighting conditions and it is easy to recall this simple color shift. At an intermediate angle, the hologram appeared with its multitude of facets of color and images.

#### Example 4

The security article of Example 3 was subjected to various tests to measure its optical performance, which are described as follows.

##### A. Instrumentation and Sample Orientation

A Zeiss GK/311M goniospectrophotometer using a xenon flash lamp with angle adjustable fiber optics for both illumination and reflectance was used to characterize the security article. Three types of viewing conditions were examined, with the geometries utilized shown in Figures 17A and 17B. These viewing conditions included: a) set angle of illumination at 45 degrees, with the angles of measurement being 5 degree increments from 65 through 155 degrees (Figure 17A); b) off-gloss, with the angles of illumination being 5 degree increments from 25 through 75 degrees and the angles of measurement being 5 degree increments from 100 through 150 degrees (Figure 17B); and c) on-gloss (specular), with the angles of illumination being 5 degree increments from 25 through 80 degrees and the angles of measurement being 5 degree increments from 100 through 155 degrees (Figure 17B). Calibration for all these geometries was made with a white tile. To test whether any orientation effects were present, the security article was oriented at 0, 90, 180 and 270 degrees with respect to the viewing optics for each viewing condition.

##### B. Optical Results

The results of optical testing for the three viewing conditions are described below. The measurements indicate that it is possible to uniquely characterize the interference optically variable effects separately from the diffractive effects.

##### 1. Set Angle of Illumination

In this configuration, the optical properties of the hologram dominated the spectral response, but only in two orientations, at 90° and 270° (*i.e.*, at 90° to the grooves of the

1 hologram). Inspection of the spectral profiles shown in the graph of Figure 18 show that the  
2 various diffractive orders of the hologram predominate. Only at small and large angle  
3 differences does the color shifting thin film show its spectra. A comparison of the color  
4 trajectory in CIE Lab color space in Figure 19 shows that the resultant color travel for the  
5 security device is due mostly to the hologram. The chroma or color saturation of the  
6 hologram is high as can be seen by the large excursions from the achromatic point ( $a^* = b^*$   
7  $= 0$ ).

## 8 2. Off-Gloss Geometry

9 In contrast to those spectral profiles found above, the off-gloss measurements showed  
10 that in this geometry, the color shifting thin film now dominated the optical response,  
11 irrespective of sample orientation. While there was no evidence of optical effects from the  
12 hologram in the  $0^\circ$  orientation, combined optical effects from the hologram and the thin film  
13 optical stack were seen in the  $90^\circ$  orientation. The spectral peaks arising from the optical  
14 stacks were modified as shown in Figure 20. The spectral profiles are typical of metal-  
15 dielectric-absorber optical stacks where the spectrum and the resultant color move to shorter  
16 wavelengths as the view angle increases. It is interesting to note that in this configuration,  
17 the brightness,  $L^*$  moves from high to low as the color changes from magenta-to-yellow. At  
18 the  $0^\circ/180^\circ$  orientation, the hologram showed no spectral peaks.

## 20 3. On-Gloss Geometry

21 In the on-gloss geometry, the security article showed two distinct features: one at  $0^\circ$ ,  
22  $180^\circ$  and one at  $90^\circ$ ,  $270^\circ$ . In the first orientation, the only optical effect was the one typical  
23 from a color shifting thin film where the color shifts to shorter wavelengths as the angle of  
24 incidence is increased. Figure 21 is a graph showing the on-gloss spectral profiles for the  
25 security article at the first orientation. The color shifts from magenta to green. Peak  
26 suppression occurs progressively as the peaks move toward the shorter wavelengths. This

1 suppression is caused, in part, by the higher reflectance values arising from the standard  
2 white tile as well as from the security article itself. Theoretically, the spectra of the thin film  
3 retain the same spectrum, but shift to shorter wavelengths as the angle of incidence increases.  
4 It should be noted that the on-gloss orientation at  $0^\circ$ ,  $180^\circ$  is well suited to machine reading  
5 since the peaks are well defined for the optical stack and are free of holographic features.

6 In the second orientation, the spectral peaks arising from the optical stack, at the high  
7 angles of incidence, show large optical interactions with the hologram. Figure 22 is a graph  
8 showing the on-gloss spectral profiles for the security article at the second orientation.

9  
10 C. Optical Microscopy

11 The security article was viewed on a Zeiss optical microscope to see the digital  
12 features encoded into the color shifting thin film. Figure 23 is a photomicrograph of the  
13 digital image (magnified 50x) in the thin film optical stack of the security article. In Figure  
14 23, the digital dots (ablation holes), where the entire optical stack is missing, have  
15 dimensions on the order of about 100 microns. Each 100 micron pixel is actually made up  
16 of 30 micron overlapping digital dots. Thus, it is possible to write covert information with  
17 30-100 micron pixel resolution, a resolution below the eye detection limit. The cracking  
18 observed in the coating is typical of dielectric films that have undergone stress relief. These  
19 cracks do not have any detrimental effect either on the optical properties or adhesion of the  
20 thin film.

21  
22 Example 5

23 A color shifting optical stack having a three-layer design was formed on an embossed  
24 transparent plastic film by direct vacuum coating of the optical stack onto a holographic  
25 surface to produce a security article. During the fabrication process, the standard aluminum  
26 layer was removed from a commercially available hologram by a dilute solution of sodium

1 hydroxide. After rinsing and drying, the embossed surface was coated in vacuum with a  
2 layer of semi-transparent metal, a layer of low index dielectric material, and finally an  
3 opaque layer of aluminum, by physical vapor deposition processes. This thin film optical  
4 stack was a Fabry-Perot filter centered at 500 nanometers. The layers could be coated in the  
5 opposite direction with a corresponding change in which side of the plastic film was  
6 modified by the optical stack.

7 When this construction was viewed through the plastic film, a superposition of the  
8 hologram and the optical stack was seen. In essence the rainbow of colors that were in the  
9 initial hologram have been modified by the optical stack whereby some colors are  
10 accentuated and some are suppressed. Actually, the hologram could be viewed from both  
11 sides; on the aluminum side the original hologram can be seen, and on the other side, the  
12 superposition of the hologram and the optical stack can be seen through the plastic film.

13 A close examination of the optical stack by scanning electron microscopy (SEM)  
14 showed that the diffractive surface pattern of the hologram was replicated up through the  
15 optical stack so that the holographic image was preserved in the aluminum surface. This is  
16 depicted in Figures 24A and 24B, which are photomicrographs of SEM images (magnified  
17 2000x and 6000x, respectively) showing holographic relief at the top of the optical stack of  
18 the security article.

1           The present invention may be embodied in other specific forms without departing  
2 from its spirit or essential characteristics. The described embodiments are to be considered  
3 in all respects only as illustrative and not restrictive. The scope of the invention is, therefore,  
4 indicated by the appended claims rather than by the forgoing description. All changes which  
5 come within the meaning and range of equivalency of the claims are to be embraced within  
6 their scope.

7           What is claimed and desired to be secured by United States Letters Patent is:

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